

DEVELOPMENT OF TiO₂ AND Bi₂O₃ THIN FILMS BY ULTRASONIC SPRAY PYROLYSIS FOR PHOTOCATALYTIC APPLICATIONS

J. Sydorenko, M. Krunks, A. Mere, N. Spalatu, M. Krichevskaya, I. Oja Acik

¹ *Department of Materials and Environmental Technology, Tallinn University of Technology, Ehitajate tee 5, 19086 Tallinn, Estonia.*

e-mail of presenting author: jekaterina.spiridono@taltech.ee

The aim of the study was to deposit TiO₂ and Bi₂O₃ thin films by ultrasonic spray pyrolysis and to investigate the influence of the processing variables, including precursor solution composition and the deposition temperature, on the photocatalytic activity. TiO₂ thin films were prepared from titanium(IV) isopropoxide (TTIP) solution at deposition temperature of 350 °C and annealed for 1 h at 500 °C. The composition of precursor solution was optimised by varying the amount of acetylacetonone (AcacH) in the solution [1]. Bi₂O₃ thin films were prepared from bismuth(III) acetate solution. The deposition temperature was optimised in the range of 250 - 450 °C and air annealed in the temperature range of 300 - 550 °C [2]. Both materials, TiO₂ and Bi₂O₃ films, were tested for photocatalytic oxidation of methyl orange (MO) dye in aqueous solutions under UV-A and visible light. In addition, TiO₂ activity was studied for oxidizing volatile organic compounds in the gas-phase [3,4].

The photocatalytic activity of TiO₂ thin films was found to increase rapidly with the increase in amount of AcacH in the precursor solution, due to the presence of incorporated carbon, which influenced the electronic structure and charge separation of the films [3]. The photocatalytic activity of Bi₂O₃ films was enhanced by higher amount of hydroxyl groups and carbon species on the surface obtained during the deposition of amorphous film and crystallization during the annealing [2]. The highest degradation of 10 ppm of MO on the TiO₂ thin film after 5 h UV-A irradiation reached 54%, while the highest degradation on the Bi₂O₃ film reached 48%.

References

1. J. Spiridonova, A. Katerski, M. Danilson, M. Krichevskaya, M. Krunks, I. Oja Acik, *Molecules*, 2019, No 24, 4326.
2. J. Sydorenko, M. Krunks, A. Katerski, R. Grzibovskis, A. Vembris, A. Mere, N. Spalatu, I. Oja Acik, *RSC Advances*, 2024, No 28, 19648-19657.
3. J. Spiridonova, A. Mere, M. Krunks, M. Rosenberg, A. Kahru, M. Danilson, M. Krichevskaya, I. Oja Acik, *Catalysis*, 2020, No 10 1011.
4. J. Sydorenko, A. Mere, M. Krunks, M. Krichevskaya, I. Oja Acik, *RSC Advances*, 2022, No 12, 35531-35542.